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### Carrier and refractive index dynamics in core-shell nanolasers grown on silicon during spontaneous and stimulated emission

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#### **ABSTRACT**

In this work, we experimentally study the carrier and refractive index dynamics of InGaAs nanopillar grown on a Si on insulator (SOI) substrate. The recombination process of the InGaAs NP is characterized with different optical techniques. Temperature dependent photoluminescence (PL) at 0.5mW excitation power is carried out to determine the influence of temperature on carrier dynamics. The radiative recombination lifetime has been studied at 7K from time-resolved photoluminescence (TRPL) experiments at a certain excitation power. The optimal combination of pitch (separation between NPs) and diameter in the growth process of this nanostructure has also been measured. These results will contribute to further optimization of the InGaAs nanolaser for integration of III-V optoelectronics on SOI substrates.

Keywords: Time resolved photoluminescence, nanolasers, SOI, III-V on Silicon

#### 1. INTRODUCTION

The applications of (nano)lasers are numerous and extremely varied. It is easy to find coherent light emitters in medicine, food science, manufacturing companies, military sector and research. III-V materials possess high gain value, direct band gap, and easy band gap tunability by varying the alloy component. The major problem of III-V materials growth in silicon is the lattice mismatch in the interface, which produces dislocation and poor performance. In III-V semiconductor nanowires (NWs) and nanopillars (NPs), the lattice mismatch can be fully relaxed over a small number of monolayers because of its small footprint. Moreover, NWs/NPs offer significant potential for nanoscale laser source due to the quasi-one-dimensional structure, which facilitates a natural Fabry-Perot resonator cavity and optical gain medium simultaneously<sup>1,2</sup>. Kim et al.<sup>3</sup> work observed stimulated light emitted from an InGaAs/InGaP core-shell NWs array at room temperature. The coherent light was resulting from the resonance in a one-dimensional photonic crystal. In this publication, the light emitted was also coupled into silicon on insulator waveguide. On the other hand, Chen et al.<sup>2</sup> group published the emission of coherent light from a single InGaAs/GaAs core-shell NP optically pumped at 4K. Strong confined helically propagating modes generated the stimulated output light. Chen et al. also modelled the relation between the NP dimension, wavelength emission and field profile for a set of helically propagating modes with FDTD techniques.

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#### 2. NANOLASER STRUCTURE AND EXPERIMENTAL SETUP

#### 2.1 Nanolaser growth and structure

In this paragraph, a brief summary of the growth process for InGaAs NPs published by Kim et al<sup>3,4</sup> will be presented. The NPs were fabricated by Hyunseok Kim at Department of Electrical Engineering, University of California Los Angeles inside the group led by Diana L. Huffaker. InGaAs NPs are grown on Silicon on insulator (SOI) (111) wafer lightly p-doped with Boron by metalorganic chemical vapour deposition (MOCVD), figure 1. The NPs features, such as diameter and separation between them (pitch), are patterned in a 20nm thick silicon nitride (Si3N4) mask for selective area epitaxy, figure 1b. Before the growth process start, the native oxide is removed by 6:1 buffered oxide etch solution for 60 s and rinsed with DI water.

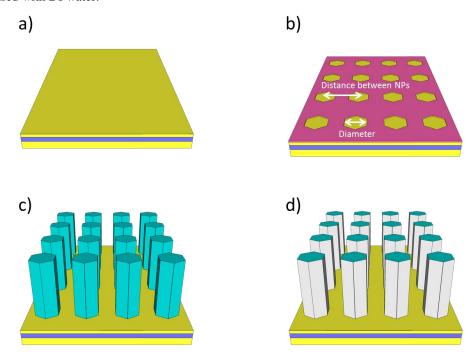


Figure 1. Schematic growth process. a, SOI (111) substrate. b, Si3N4 mask with lithography pattern. c, InGaAs NP growth. d, passivation with InGaP.

Triethylgallium (TEGa), trimethylindium (TMIn), and tertiarybutylarsine (TBAs) are used as precursors and hydrogen as a carrier gas. The sample is first baked for thermal de-oxidation at 860 °C and 13 minutes in the MOCVD reactor. Then, the temperature is decreased to 690 °C, and the InGaAs nanopillar growth is initiated by flowing TEGa, TMIn, and TBAs simultaneously. The molar flow rates used corresponds to a gas phase composition of In/(In+Ga)=0.257 and V/III flow rate ratio of 24.1, figure 1c. The InGaAs/InGaP core-shell NPs are passivated in-situ by growing InGaP shells for 45 s at 600 °C with gas phase indium composition (In/(In+Ga)) of 0.75, figure 1d. Finally, the sample is cooled down with TBAs to prevent desorption.

#### 2.2 Time resolved PL set-up

**Error! Reference source not found.** shows the experimental photo-luminescence set-up to characterise the GaAs NWs and InGaAs NPs. The excitation source is a pulsed Ti-Saphire laser. The wavelength can be tuned from 690 nm to 1000 nm, and the pulse width is approximately 200 fs. The laser beam is guided to a neutral-density filter to have control of the excitation power amount. The micorscope lens is a 50x Olympus silicone achromatic with numerical aperture of 0.65. In order to visualise the sample and the laser beam location, a 660 nm LED source and CMOS camera is placed in the set-up. The sample emission is guided with beamsplitters to the lens that focuses it on the monochromator. The

monochromator filters the light and sends it to the femtowatt photodetector, or the streak camera. The sample is placed in a Helium continuous flow liquid Helium cryostat.

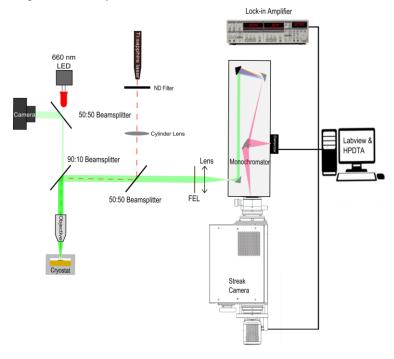


Figure 2. Figure captions are indented 5 spaces and justified. If you are familiar with Word styles, you can insert a field code called Seq figure which automatically numbers your figures.

#### 3. SPONTANEOUS AND STIMULATED EMISSION FROM INGAAS NANOLASERS

The emission dynamics of InGaAs NPs was studied for excitation power below and above the lasing threshold. The time evolution for InGaAs NP emission showed a decrease of carrier lifetime with the transition from spontaneous to stimulated carrier recombination process. The optical properties of passivated and unpassivated InGaAs NPs ware also compared. Passivated NPs showed an increase of the carrier lifetime due to the reduction of non-radiative process on the NP surface. Finally, the polarisation study revealed a circular polarisation light for a helical mode propagating inside the InGaAs/InGaP NP.

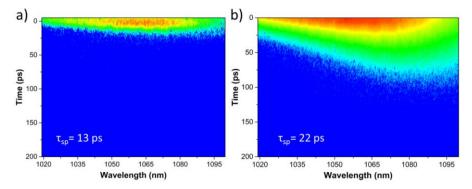


Figure 3. Evolution of time resolved PL under optical pulsed excitation with pump power density corresponding to spontaneous light emission from the unpasivated nonpolar.

Figures 3 and 4 are presenting time resolved emission measurements below and above lasing threshold respectively. At the fig. 4b there is single longitudal lasing mode with clear spectral narrowing and decay time of 6ps which is at the edge of the system temporal resolution.

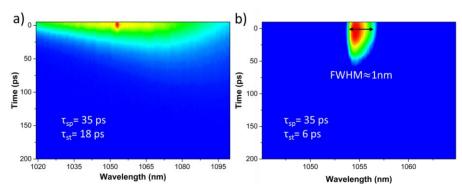


Figure 4. TRPL measurements of InGaAs NPs with 500 nm pitch and 80 nm nanohole diameter at 7 K. a, excitation power of 160 kW/cm2 (a). Excitation power of 180 kW/cm2 with the high-spectral resolution measurement (b).

Passivated InGaAs nanolasers characterize significantly brighter and temporarly longer spontaneous light emission. The examined laser has its F-P mode slightly outside the gain curve. Big longitudal mode spectral separation (in order of 100nm) makes those nanolasers single mode operating devices without any additional processing. Unfortunately the passivated nanolaser F-P mode spectral position is placed at the shoulder of the gain curve.. Due to this fact the laser did not improve threshold value compare to unpassivated laser. Fig. 5 presents Light input light output curve (a) and position of the fast decaying stimulated emission peak (835nm) on the high energy shoulder of the long decaying broad spontaneous emission.

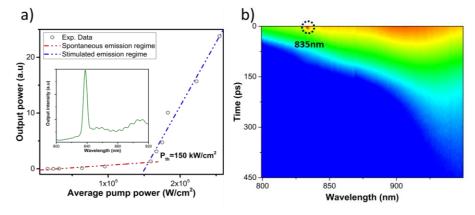


Figure 5. Light input – light output curve for passivated nanolaser structure and optical emission specrtum just above the threshold in the insert (a). Time resolved photoluminescence immage containing two different features: broad long decaying spontaneus emission centered around 925nm and spectraly narrow emission, very short decaying F-P single mode just above lasing threshold at 835nm.

#### 4. CONCLUSIONS

The optical properties of passivated and unpassivated InGaAs NPs have been compared in the means of micro-TRPL experiments. The study of carrier lifetime and spectral emission intensity as a function of the excitation power determined the lasing threshold pump power density at the similar level for both unpassivated and passivated NPs. The spontaneous emission intensity for passivated structure is significantly brighter and decays longer, this indicates efficient

blockage of surface carrier recombination in the NPs. Our experiments also shown that F-P resonance spectral position is extremally critical for reduction lasing threshold thus precise control of the NPs height during growth process is crucial to achieve perfect spectral tuning of the gain curve and F-P resonance.

#### **ACKNOWLEDGMENTS**

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